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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/642,266	08/18/2003	Ayako Nakano	03180.0332	2400	
22852 73	7590 04/15/2005		EXAMINER		
FINNEGAN, LLP	HENDERSON, FAR	SIEK, VUTHE			
	RK AVENUE, NW	ART UNIT	PAPER NUMBER		
	N, DC 20001-4413	2825			

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Applicati	on No.	Applicant(s)			
		10/642,2	66	NAKANO ET AL.			
Office	Action Summary	Examine	r	Art Unit			
		Vuthe Sie		2825			
The MAIL	NG DATE of this commu	nication appears on th	e cover sheet with the d	orrespondence addre	ess		
THE MAILING D. - Extensions of time mafter SIX (6) MONTH - If the period for reply - If NO period for reply - Failure to reply within Any reply received by	STATUTORY PERIOD IN ATE OF THIS COMMUNAL BY BE AVAILABLE UNDER THE PROVISION S from the mailing date of this come specified above is less than thirty (is specified above, the maximum set the set or extended period for replote the Office later than three months djustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In no evenunication. 30) days, a reply within the statistatutory period will apply and very will, by statute, cause the ap	vent, however, may a reply be tin tutory minimum of thirty (30) day vill expire SIX (6) MONTHS from olication to become ABANDONE	nely filed s will be considered timely. the mailing date of this comn D (35 U.S.C. § 133).	nunication.		
Status							
1) Responsive	e to communication(s) fil	ed on 18 August 200	<u>3</u> .				
2a) This action	• • •	2b)⊠ This action is a	-				
3) Since this	application is in condition	for allowance excep	t for formal matters, pro	secution as to the m	ierits is		
closed in a	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Clain	ns						
4a) Of the a 5)⊠ Claim(s) <u>5</u> , 6)⊠ Claim(s) <u>1</u> . 7)□ Claim(s)	Claim(s) 1-18 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. Claim(s) 5,6,11,12,17 and 18 is/are allowed. Claim(s) 1-4,7-10 and 13-16 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or election requirement.						
Application Papers							
10) The drawing Applicant m	cation is objected to by the g(s) filed on 18 August 2 ay not request that any object drawing sheet(s) including the declaration is objected to	003 is/are: a)⊠ acceed action to the drawing(s) g the correction is requi	be held in abeyance. Sered if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR			
Priority under 35 U.	S.C. § 119						
a)⊠ All b)□ 1.⊠ Certi 2.□ Certi 3.□ Copi appli	gment is made of a claim Some * c) None of: Ified copies of the priority es of the certified copies ication from the Internati ched detailed Office action	y documents have been documents have been to fithe priority documents and Bureau (PCT Ru	en received. en received in Applicati ents have been receive le 17.2(a)).	ion No ed in this National St	age		
Attachment(s)							
1) Notice of Reference		272 040	4) Interview Summary				
	son's Patent Drawing Review (ure Statement(s) (PTO-1449 o ate <u>8/18/03</u> .		Paper No(s)/Mail D 5) Notice of Informal F 6) Other:		52)		

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DETAILED ACTION

1. This office action is in response to application 10/642,266 filed on 8/18/2003.

Claims 1-18 remain pending in the application.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1, 7 and 13 are rejected under 35 U.S.C. 102(e) as being anticipated by Falbo et al. (US 2003/0163791).
- 3. As to claims 1, 7 and 13, Falbo et al. teach a shape-based geometry engine to perform smoothing and other layout beautification operations (correcting pattern design layout). The shape-based geometry correction engine prepares a mask pattern used in a lithography process for transferring a circuit pattern intersecting with a step pattern on a substrate which has the step pattern designed thereon (Example shown in Fig. 3a and 3b, 5a-c, 11a-c). Then the shape-based geometry correction engine applies actions or correction patterns to the mask pattern accordance with correction rules considering a shape of the step pattern (0044-0047, 0050-0055, 0097, 0098). As shown in Fig. 3a, there is an overlapping region between the patterns 310 and 320 that forms a

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connection there between. This clearly shown intersection of edges of the circuit pattern and the step pattern (pattern 310 and pattern 320) as shown in Fig. 3b (combined pattern 350). Then, the shape-based correction engine applies a desired corrective action to the combined pattern 350 that include both the circuit pattern and the step pattern (pattern 310 and 320, as shown as item 350 of Fig. 3B). Accordingly, the desired corrective action is applied at the intersections of edges of the circuit pattern and the step pattern and in the vicinity of the intersections, thereby the desired corrective action associated with the shape pattern 350 that include both the circuit pattern and the step pattern (pattern 310 and pattern 320) and the intersections of edges and the vicinity of the intersections can accurately widen and align the correction formed by the edges 323-325 of interconnect polygon 320 with gate 310.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 2-3, 8-10 and 14-15 are rejected under 35 U.S.C. 103(a) as being obvious over Falbo et al. (US 2003/0163791) in view of Ahrens et al. (6,664,010).
- 6. As to claims 2, 8 and 14, although it is well known in the art that using lithography simulations to perform proximity correction based on correction rules, Falbo et al. does not explicitly teach that. Ahrens et al. teach the claimed limitation (col. 3, lines 1-16, col.

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6, lines 1-20). Using lithography simulations based on correction rules and applying in Falbo et al. corrective action, it would have been obvious to one of ordinary skill in the art the claimed limitation because this would accurately correct the design pattern including the intersections of edges of the combined patterns to comply with design rules as required.

- 7. As to claims 3, 9 and 15, Falbo et al. teach the shape of the step pattern includes pattern width/height/length as two-dimensional shapes of the patterns (Fig. 2-6, 11-12).
- 8. Claims 4, 10 and 16 are rejected under 35 U.S.C. 103(a) as being obvious over Falbo et al. (US 2003/0163791) in view of Ahrens et al. (6,664,010) and further view of Yoshida (6,268,234).
- 9. As to claims 4, 9 and 16, Falbo et al. and Ahrens et al. do not teach the circuit pattern defines impurity implantation regions. Yoshida teach forming the readout gate sections by implementing an impurity into the readout gate section forming regions and photosensor forming regions of a substrate at the same time in a device forming step in which an impurity is implanted into the substrate in order to resolve the problem of misregistration of photomask during manufacturing (col. 3 lines 1-40; col. 5 lines 1-50). By combining these teachings, it would have been obvious to one of ordinary skill in the art at the time the invention was made the claimed invention because implanting an impurity would also increase transfer efficiency thereby the circuit pattern can be formed accurately.

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Allowable Subject Matter

10. Claims 5-6, 11-12 and 17-18 are allowed over the prior art of record.
The prior art of record does not teach or fairly suggest measuring step and reviewing step as recited in the claims.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Vuthe Siek whose telephone number is (571) 272-1906. The examiner can normally be reached on Increase Flextime.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Vuthe Siek

VUTHE SIEK PRIMARY EXAMINER

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